IDS Form PTO/SB/08: Substitute for form 1449A/PTO			Complete if Known	
			Application Number	10/565,389
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			First Named Inventor	Yoshitaka SUGAWARA
			Art Unit	2838
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U.S. PATENTS AND PUBLISHED U.S. PATENT APPLICATIONS

Examiner Initials	Cite No.[1]	Document Number — Number-Kind Code[2] *(if known)*	Issue or Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		US-			
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Note: Submission of copies of U.S. Patents and published U.S. Patent Applications is not required.

FOREIGN PATENT DOCUMENTS

Examiner Initials	Cite No.[1]	Foreign Patent Document — Country Code[3] Number[4] Kind Code[5] *(if known)*	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation[6]
/AW/		JP 06-113559	04/22/1994	Mitsubishi Heavy Ind. Ltd		Abstract
/AW/		JP 2000-295863	10/20/2000	Mitsubishi Electric Corp.		Abstract
/AW/		JP 2002-111010	04/12/2002	Hitachi Ltd		Abstract

NONPATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No.[1]	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation[6]
/AW/		Decision of Refusal in corresponding Japanese Patent Application 2003-279312, dated 9/8/2008.	Yes

Examiner Signature	/Arun Williams/	Date Considered	03/14/2009

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.